

Title (en)

ORGANIC ELECTROLUMINESCENT MATERIALS AND DEVICES

Title (de)

ORGANISCHE ELEKTROLUMINESZENTE MATERIALIEN UND VORRICHTUNGEN

Title (fr)

MATÉRIAUX ET DISPOSITIFS ÉLECTROLUMINESCENTS ORGANIQUES

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Abstract (en)

The present invention includes novel organic materials containing indolo[3,2-b]carbazoles and terphenyls. The compounds and materials of the present invention may be useful for PHOLED devices.

IPC 8 full level

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